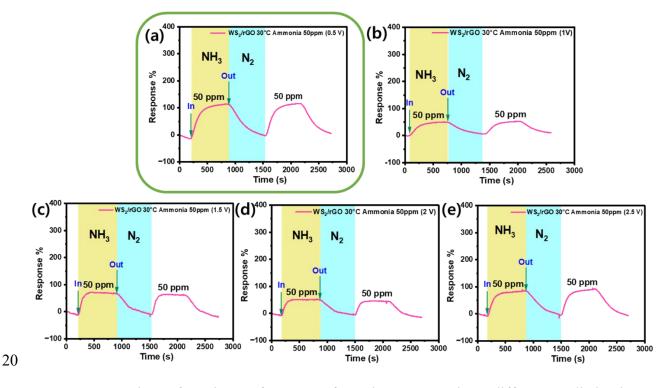
Electronic Supplementary Material (ESI) for Journal of Materials Chemistry A. This journal is © The Royal Society of Chemistry 2024

1	Supporting Data
2	Live-tracking of beef freshness at sub-ppb level ammonia detection with synergistic
3	advancement in WS ₂ /rGO nanoflakes by edge site enriched acidic sulfur
4	
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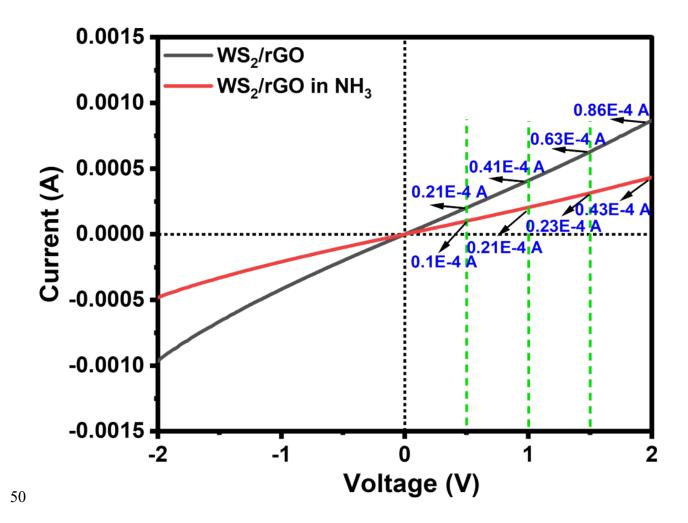
S1



21 Fig. S1. Comparison of sensing performance of WS₂/rGO composite at different applied voltage.
22 (a) 0.5V. (b) 1V. (c) 1.5V. (d) 2V. (e) 2.5V.

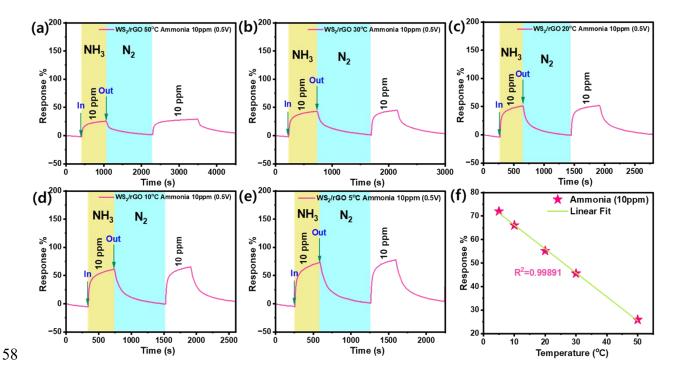
The sensor's response as functions of the provided bias voltage. At 0.5 V, the response rises to 120 (a), and at 2.5 V, it falls by 30 (e). The recovery also declines, going from 662 seconds at 0.5 V to 133 seconds at 1 V and finally to 377 seconds at 2.5 V. These findings are highly intriguing given that optimizing the applied voltage alone significantly improves sensing performance of the sensing electrode. Sensing response at 0.5 V showed the best response and recovery in comparison to the rest of the four volts, as represented in (a). Also, 0.5 V operating voltage supports our wireless device to be operated based on a coin cell.

32 The performance of a p-type semiconductor is significantly influenced by the exact location of the 33 Fermi level. A crucial factor since it has a significant impact on the thermal, electrical, and, ultimately, functional characteristics of a semiconductor device. In p-type semiconductors, a closer 34 35 Fermi level to the valence band results in more holes, which influence the behavior of the 36 semiconductor as a whole because they are the majority carrier. A semiconductor is classified as p-type if its Fermi level is closer to the valence band and as n-type if it is closer to the conduction 37 band. The application of an external voltage can alter this flow of holes or electrons, permitting 38 the change in flow of current (positive or negative) and as applied voltage increases the 39 conductivity decreases (hole-electron pair) and sensing response decreases. That said, the Fermi 40 level positioning isn't static. The number of hole-electron pairs enhances, the Fermi level also 41 moves towards the center of the bandgap, becoming intrinsic (less presence of electron in p-type 42 semiconductors). The increase in intrinsic carriers alters the carrier distribution and thus affects 43 the device's operation. As a result, in presence of ammonia additional electrons adsorbs on the 44 surface having less holes (less conduction) leading to the accumulation of electrons over the 45 surface or in other words less holes are available to interact with ammonia donated electrons, hence 46 enhancing the conductivity of the material (high electron density, influencing the nature of p-type 47 semiconductor) due to which at high voltage, low response resistance was observed.¹⁻⁴ 48



51 Fig. S2. I-V study for WS_2/rGO composite in presence and absence of NH_3 .

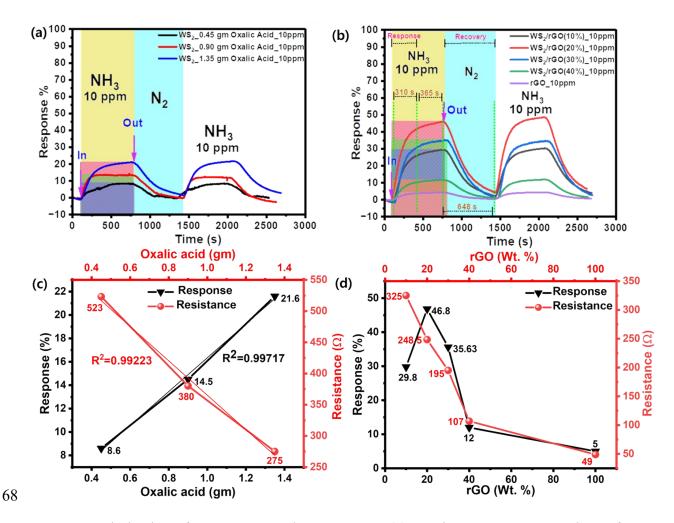
52 I-V curve revealed that upon increasing voltage the current intensity also increased in presence of 53 air and in presence of NH_3 same trend was observed but the current intensity is lower as compared 54 to air environment. So, as the resistance is increasing it is supporting the sensing mechanism, for 55 this reason we have chosen low voltage-high resistance parameter. Furthermore, our objective is 56 to operate a commercial device so we have targeted low energy consumption which will be suitable 57 for a coin cell-based device.



59 Fig. S3. Comparison of sensing performance of WS₂/rGO composite at different temperatures. (a)
60 50°C. (b) 30°C. (c) 20°C. (d) 10°C. (e) 5°C.

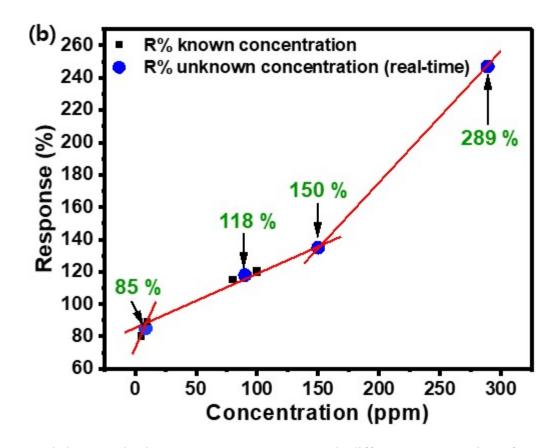
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62 Temperature dependent study for the optimization of working temperature. Sensing response is 63 inversely proportional to the temperature, on decreasing temperature the sensor showed more 64 higher response. (b) According to the real-time monitoring target we operated all experiments at 65 30°C. (f) The relationship between temperature and response showed a linear trend with an R² 66 value of 0.99891.



69 Fig. S4. Optimization of OA content and rGO content. (a) Sensing response comparison of WS_2 70 with different OA content. (b) Sensing response comparison of WS_2/rGO with different rGO 71 content. (c) Linear fit of sensing response and resistance of WS_2 with different OA content. (d) 72 linear fit for sensing response and resistance comparison of WS_2/rGO with different rGO content. 73

74 Oxalic acid content and rGO wt. % optimization for best performance of the sensor. (a and c) 75 Sensing response is proportional to the oxalic acid concentration, on increasing oxalic acid (1.35 76 gm) amount the sensor showed higher response, showed linear trend with R² vale of 0.99717. (b and d) 20 wt. % of rGO compared to 100 wt. %, 10 wt. %, 30 wt. %, and 40 wt. %, showed highest
sensing response towards NH₃ at RT.



81 Fig. S5. Real-time monitoring sensor response % towards different concentration of NH_3 during 82 meat spoilage. Comparison and calculation of unknown concentration of NH_3 during meat spoilage 83 to set the admissible range for meat freshness. Below 150 response % meat is admissible to 84 consume.

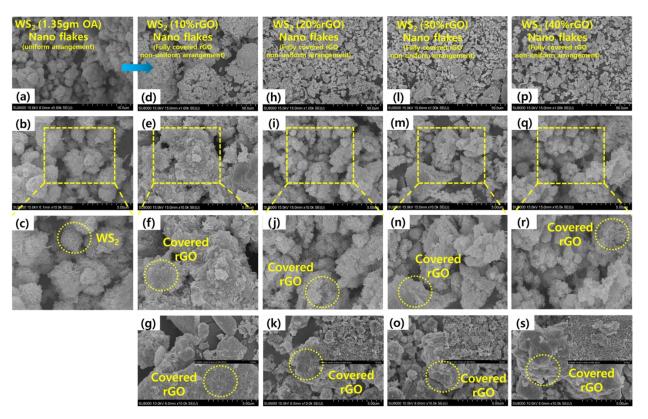
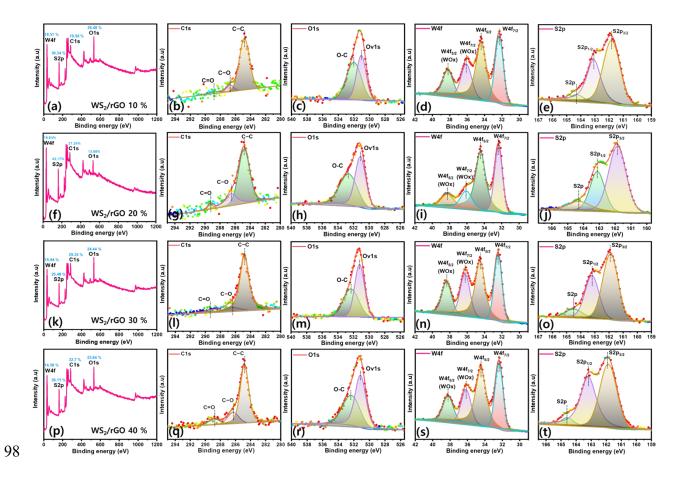


Fig. S6. HRSEM images of pristine WS₂ and all four composites at different magnifications to
showcase the presence of rGO in all composites and their structural modifications. (a-c) WS₂. (dg) WS₂ (10% rGO). (h-k) WS₂ (20% rGO). (l-o) WS₂ (30% rGO). (p-s) WS₂ (40% rGO).

90 HRSEM is used to examine the microstructure and morphology of all four composites. HRSEM images at various magnifications are shown in Fig. S6a-s. Synthesized sulfur-rich WS₂/rGO 91 composites were primarily composed of nanoflakes (Fig. S6f,j,n, and r). High-magnification SEM 92 93 (Fig. S6f, j, n, and r) revealed details of the microstructure of WS₂ nanoflakes and showed that they 94 homogeneously and completely decorated rGO. Furthermore, the presence of rGO is shown in fig. S6g,k,o, and s, which represents that the morphology is disrupting over the addition of high rGO 95 96 content (10%, 20%, 30%, and 40%) simultaneously maintaining the homogenous covering of all 97 rGO particles.

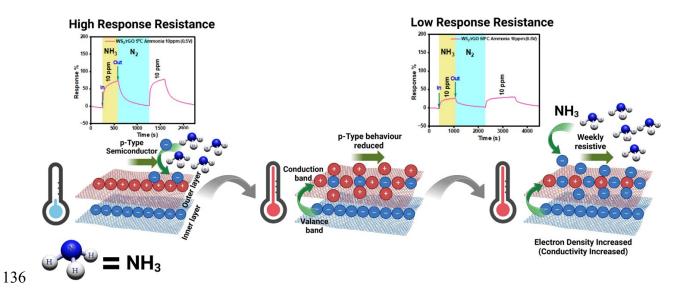


99 **Fig. S7.** XPS survey spectra of all four sulfur-rich WS₂/rGO composite; (a) WS₂ (10% rGO). (f) 100 WS₂ (20% rGO). (k) WS₂ (30% rGO). (p) WS₂ (40% rGO) full scan survey spectra. (b-e) C1s, 101 O1s, W4f, and S2p for WS₂ (10% rGO) composite. (g-j) C1s, O1s, W4f, and S2p for WS₂ (20% 102 rGO) composite. (l-o) C1s, O1s, W4f, and S2p for WS₂ (30% rGO) composite. (q-t) C1s, O1s, 103 W4f, and S2p for WS₂ (40% rGO) composite.

105 XPS analysis was performed to classify the molecular phases and oxidation states in all four 106 different compositions of composites to evaluate the content ratio of all samples. The four core 107 level peaks for W 4f, S 2p, C 1s, and O 1s are presented in (Fig. S7a,f,k and p) for all four samples 108 (WS₂/rGO-10%, 20%, 30% and 40%), the percentage of carbon has increased with increase in

109 rGO content, the best performed composition with 20% rGO showed the least O₂ presence and 110 highest W and S presence among all four compositions. The three core functional peaks at 284.8 eV (C-C), 286.4 eV (C-O), and 289.2 eV (C=O) represent C bonding (Fig. S7b,g,l, and q) and 111 112 depict the C 1s deconvoluted spectrum of the sulfur-rich WS₂/rGO composites. Less intense O-113 bond signals in the C 1s spectrum of the composite further support its lower O-content. Observation of less O 1s state in the WS₂/rGO nanohybrids showed that the hydrothermal 114 procedure effectively reduced GO to rGO. Fig. S7c,h,m, and r, shows the O 1s information, in 115 which the main peak of O at 531.11 eV implies the existence of O-W bond in WS₂/rGO 116 composites. In addition, a small peak at 532.65 eV is attributed to the sub-stoichiometric form of 117 118 WS₂/rGO composites. The binding energies of two satellite shakeup peaks at 32.39 and 34.42 eV (Fig. 5d,i,n, and s) showed W 4f_{7/2} and W 4f_{5/2} are distinguishing features. Simultaneously, the 119 modest peaks at 36.11 and 38.24 eV were attributed to W $4f_{7/2}$ and W $5p_{3/2}$ of oxides originating 120 121 from WO_x and higher binding energies on the surface of the as-prepared sulfur-rich composites, notably 20% rGO ratio showed the least "O2" presence with least intense peaks at 36.11 and 38.24 122 eV. Fig. S7e, j,o, and t, depicts the spectrum of S 2p, the binding energies of peaks at 161.86, 123 163.13 eV, and 164.29 eV denote divalent sulfide ions of S 2p_{3/2}, S 2p_{1/2}, and S 2p orbitals, 124 respectively, used for W-S bonding. This shows the existence of unsaturated sulfur, and no S-O 125 126 interaction peak was observed which supports the sensing mechanism or best performing 127 composition (WS₂/rGO 20%). A possible site for humidity (RH) interaction. Two fundamental S $2p_{1/2}$ and S $2p_{3/2}$ peaks represent the common orbital states of S electrons. S has a valence of -2 in 128 WS_2 and is represented by a pair of S $2p_{1/2}$ and S $2p_{3/2}$ peaks. Because of the possibility that the 129 existence of sulfonated species ($-SO_3H$, the valence of S is +4) in the sulfur-rich WS₂/rGO 130 S11

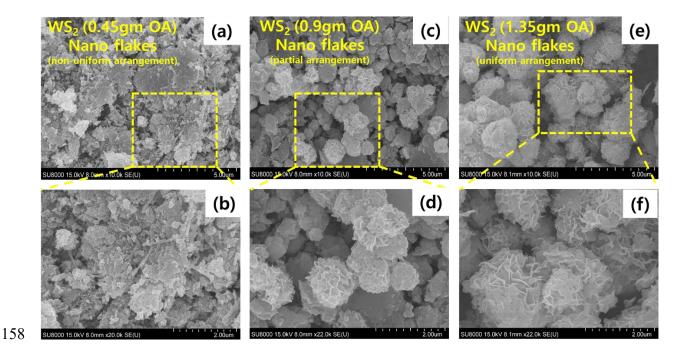
- 131 heterojunction, acid centers may inhibit. Thus, the peak of acid centers (SO_4^{2-} , the valence of S is
- 132 +6) is absent in Fig. S7e, j,o, and t. A certain rise may be seen in the area ratio between $S2p_{1/2}$ and
- 133 S2 $p_{3/2}$, which indicates an increase in S⁴⁺ content. With a +4 valence of the S element, it represents
- 134 the existence of sulfonated species –SO₃H and sulfur richness of the composite material.



137 Fig. S8. Schematic presentation of sensing mechanism at low and high temperature.

139 In P-type semiconductors, the conductivity (flow of positive charge) decreases with increasing 140 temperature due to the decrease in number of holes. At low temperatures, the holes are highly 141 concentrated and act as majority charge carriers, while at the higher temperatures, thermal energy promotes some of the holes to the valance band, reducing the number of available holes for 142 143 conduction or the intrinsic charge carrier concentration (i.e., electron-hole pair) also increases. With more pairs, holes can recombine with electrons, reducing the rate of hole flow, and 144 consequently, the conductivity drops. Simultaneously, in presence of ammonia additional 145 146 electrons adsorbs on the surface having less holes (less conduction) leading to the accumulation of 147 electrons over the surface or in other words less holes are available to interact with ammonia 148 donated electrons, hence enhancing the conductivity of the material (high electron density, 149 influencing the nature of semiconductor) due to which at high temperature, low response resistance 150 was observed. This behavior can be explained by the band theory of solids. In semiconductors, the

151 valence band and conduction band are separated by a band gap, which determines the energy 152 required for an electron to move from the valence band to the conduction band and become a free 153 electron. At low temperatures, the electrons are mostly in the valence band, and few are able to 154 overcome the energy barrier and enter the conduction band (nature of p-type semiconductors). 155 However, as the temperature increases, more electrons are able to gain enough thermal energy to 156 move into the conduction band, increasing the conductivity.⁴⁻⁷



159 Fig. S9. HRSEM images of WS₂ with different OA content at different resolutions. (a, b) WS₂
160 (0.45 gm OA). (c, d) WS₂ (0.45 gm OA). (e,f) WS₂ (0.45 gm OA).

162 HRSEM is used to examine the microstructure and morphology of all three pristine WS_2 163 nanomaterials (Fig. S9a,c, and e). HRSEM images at high magnifications are shown in Fig. S9b,d, 164 and f. Synthesized sulfur-rich WS_2 nanomaterials were primarily composed of nanoflakes. High-165 magnification of all three samples revealed details of the microstructure of WS_2 nanoflakes and 166 showed that on increasing oxalic acid (OA) content the best performed pristine nanomaterial (WS_2 , 1.35 gm OA) showed the perfect microstructure with homogenous formation of nanoflakes.

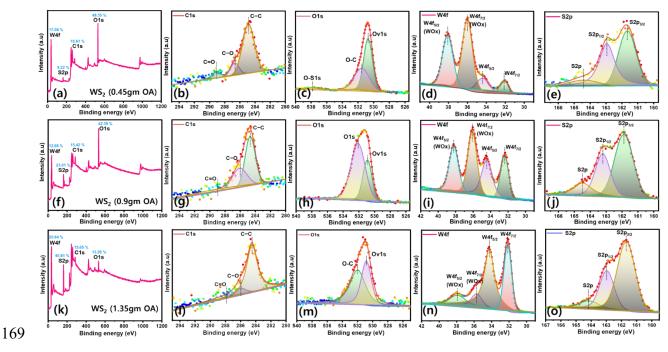
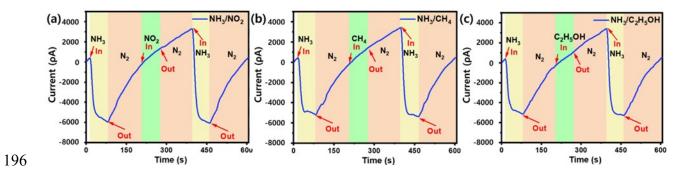


Fig. S10. XPS survey spectra of all three pristine WS_2 with different OA content; (a) WS_2 (0.45 gm OA). (f) WS_2 (0.90 gm OA). (k) WS_2 (1.35 gm OA). full scan survey spectra. (b-e) C1s, O1s, W4f, and S2p for WS_2 (0.45 gm OA). (g-j) C1s, O1s, W4f, and S2p for WS_2 (0.90 gm OA). (l-o) C1s, O1s, W4f, and S2p for WS_2 (1.35 gm OA).

XPS analysis was performed to classify the molecular phases and oxidation states in all three 175 pristine WS₂ samples to evaluate the effect of OA. The four core level peaks for W 4f, S 2p, C 1s, 176 177 and O 1s are presented in (Fig. S10a,f, and k) for all three samples (WS₂ with 0.45, 0.9, and 1.35 gm OA). The best performed pristine nanomaterial (WS₂ with 1.35 gm OA) showed the sulfur 178 richness and highest intensities of W4f peaks at the binding energies of two satellite shakeup peaks 179 at 32.39 and 34.42 eV (Fig. S10n) showed W $4f_{7/2}$ and W $4f_{5/2}$ are distinguishing features. 180 Simultaneously, the modest peaks at 36.11 and 38.24 eV were attributed to W $4f_{7/2}$ and W $5p_{3/2}$ of 181 oxides originating from WO_x which are least intense compared to less content of OA samples. 182

183 Notably presence of 1.35gm OA showed the least "O₂" presence with least intense peaks at 36.11 184 and 38.24 eV (Fig. S10k). Fig. S10e, j, and o, depicts the spectrum of S 2p, the binding energies of peaks at 161.86, 163.13 eV, and 164.29 eV denote divalent sulfide ions of S 2p_{3/2}, S 2p_{1/2}, and S 185 186 2p orbitals, respectively, used for W-S bonding. This shows the existence of unsaturated sulfur. 187 Two fundamental S 2p_{1/2} and S 2p_{3/2} peaks represent the common orbital states of S electrons. S has a valence of -2 in WS₂ and is represented by a pair of S $2p_{1/2}$ and S $2p_{3/2}$ peaks. Because of the 188 189 possibility that the existence of sulfonated species (-SO₃H, the valence of S is +4) in the sulfurrich WS₂ heterojunction, acid centers may inhibit. Thus, the peak of acid centers (SO₄²⁻, the 190 valence of S is +6) is absent in Fig. S7e, j, and o. A certain rise may be seen in the area ratio between 191 $S2p_{1/2}$ and $S2p_{3/2}$, which indicates an increase in S^{4+} content. With a +4 valence of the S element, 192 it represents the existence of sulfonated species -SO₃H and sulfur richness of the composite 193 194 material.



197 **Fig. S11a.** Cross reactivity analysis for BLE device integrated with fabricated sensor for different 198 gases (separately). (a) NO₂. (b) CH₄. (c) C_2H_5OH .

199 In presence of NO₂, CH₄, C₂H₅OH (Fig. S11a: a, b, c, respectively) gases no interference was

200 observed, which proves that sulfur-rich WS₂/rGO nanohybrid is highly specific towards NH₃ gas.

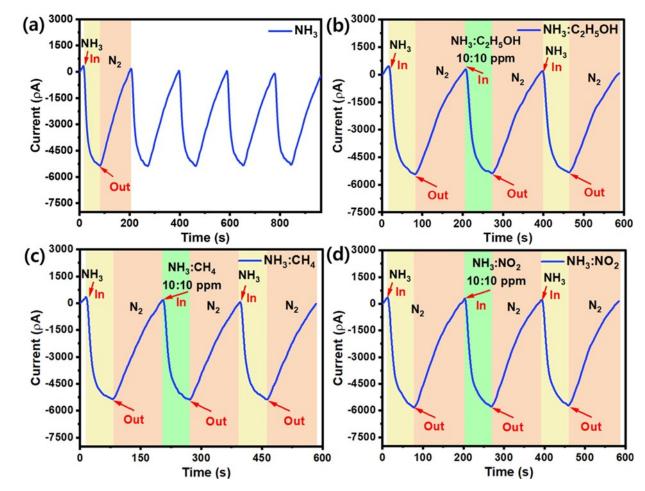
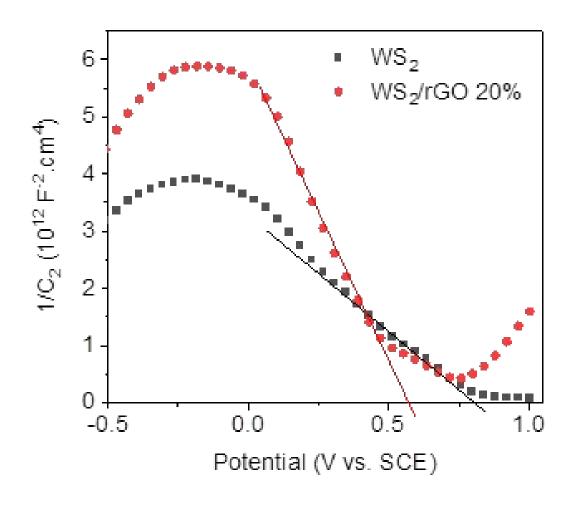


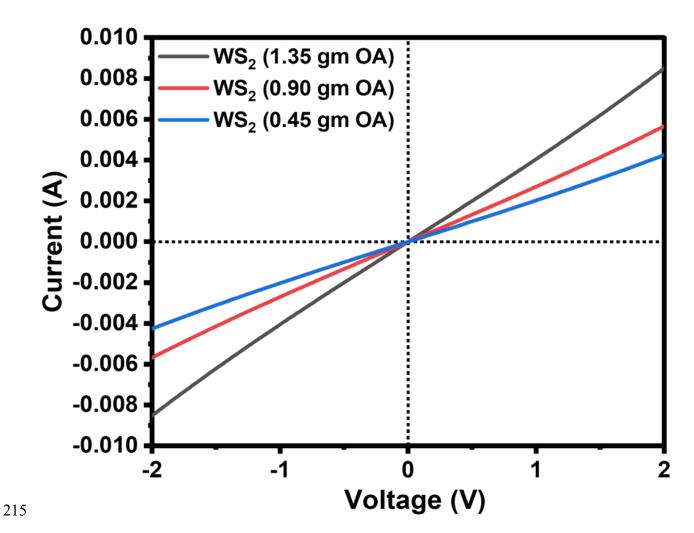
Fig. S11b. Cross reactivity analysis for BLE device integrated with fabricated sensor for different
gases (mixture). (a) NH₃. (b) NH₃:C₂H₅OH. (c) NH₃:CH₄. (d) NH₃:NO₂.

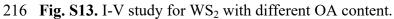
205 In presence of $NH_3:NO_2$, $NH_3:CH_4$, $NH_3:C_2H_5OH$ (Fig. S11b: a, b, c, d, respectively) mixture of 206 gases no interference was observed, which again proves that sulfur-rich WS_2/rGO nanohybrid is 207 highly specific towards NH_3 gas (Video S1).



210 Fig. S12. Mott Schottky plot for all three samples rGO, WS_2 , WS_2/rGO .

211 M-S plot showed the p-type behavior of the semiconductor. Sulfur richness and nitrogen 212 environment played a crucial role in making WS_2 and rGO as a p-type semiconductor as S and N 213 acted as acceptor and supported (enhanced) the interaction of NH_3 electrons.





.%	R%	PPM	A duningihla
			Admissible
30	85	8.4	0
39	118	90	0
15	135	150	X
20	247	289	X
	15 20		

218 Table S1. Ammonia ppm calculation for real time monitoring of meat freshness

219

221 Table S2. rGO content calculation for all four composites

rGO (40ml GO solution)	WS ₂ (40ml solution)	WS ₂ /rGO 10% (40ml solution)	WS ₂ /rGO 20% (40ml solution)	WS ₂ /rGO 30% (40ml solution)	WS ₂ /rGO 40% (40ml solution
250	250	62.5/350	125/350	187.5/350	250/350
250 mg	350 mg	Ratio: 18	Ratio: 35	Ratio: 53	Ratio: 71

XPS analysis for rGO content in WS_2/rGO nanohybrid

85.91 % 17.65 %	19.52-17.65	24.24-17.65 %	29.35-17.65 %	32.7-17.65 % =
	% = 1.87 %	= 6.59 %	= 11.7 %	15.05 %

222

Composite С % 0% W % S % WS₂/rGO 10% 18.51 19.58 26.48 30.34 WS2/rGO 20% 13.68 19.94 43.17 21.24 WS₂/rGO 30% 29.35 24.44 15.94 25.48 WS₂/rGO 40% 32.7 23.64 14.58 26.15

224 Table S3: Comparison of C, O, W, and S atomic % in all composites

227 Video S1: Working demonstration of BLE sensing device for NH₃:C₂H₅OH mixture in same228 cycles.

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232	References

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